

## PCT REQUEST

PH-20159-PCT

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<b>0</b>	<b>For receiving Office use only</b>	
<b>0-1</b>	International Application No.	
<b>0-2</b>	International Filing Date	
<b>0-3</b>	Name of receiving Office and "PCT International Application"	
<b>0-4</b>	<b>Form - PCT/RO/101 PCT Request</b>	
<b>0-4-1</b>	Prepared using	<b>PCT-EASY Version 2.92 (updated 01.07.2003)</b>
<b>0-5</b>	<b>Petition</b> The undersigned requests that the present international application be processed according to the Patent Cooperation Treaty	
<b>0-6</b>	<b>Receiving Office (specified by the applicant)</b>	<b>Korean Intellectual Property Office (RO/KR)</b>
<b>0-7</b>	<b>Applicant's or agent's file reference</b>	<b>PH-20159-PCT</b>
<b>I</b>	<b>Title of invention</b>	<b>METHOD AND APPARATUS FOR PRODUCING AMORPHOUS ALLOY SHEET, AND AMORPHOUS ALLOY SHEET PRODUCED USING THE SAME</b>
<b>II</b>	<b>Applicant</b>	
<b>II-1</b>	This person is:	<b>applicant only</b>
<b>II-2</b>	Applicant for	<b>all designated States except US</b>
<b>II-4</b>	Name	<b>POSTECH FOUNDATION</b>
<b>II-5</b>	Address:	<b>San 31 Hyoja-dong, Nam-gu 790-784 Pohang-city, Kyungsangbuk-do Republic of Korea</b>
<b>II-6</b>	State of nationality	<b>KR</b>
<b>II-7</b>	State of residence	<b>KR</b>
<b>II-8</b>	Telephone No.	<b>82-54-279-2571</b>
<b>II-9</b>	Facsimile No.	<b>82-54-279-2580</b>
<b>II-11</b>	Applicant's registration No. with the Office	<b>2-1999-900096-8</b>

III-1	<b>Applicant and/or inventor</b>	
III-1-1	This person is:	applicant and inventor
III-1-2	Applicant for	US only
III-1-4	Name (LAST, First)	LEE, Jung-Gu
III-1-5	Address:	Center for Advanced Aerospace Materials, Pohang University of Science and Technology, San 31 Hyoja-dong, Nam-gu 790-784 Pohang-city, Kyungsangbuk-do Republic of Korea
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III-1-7	State of residence	KR
III-2	<b>Applicant and/or inventor</b>	
III-2-1	This person is:	applicant and inventor
III-2-2	Applicant for	US only
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III-2-7	State of residence	KR
III-3	<b>Applicant and/or inventor</b>	
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III-3-2	Applicant for	US only
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III-3-6	State of nationality	KR
III-3-7	State of residence	KR

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III-4	<b>Applicant and/or inventor</b>	
III-4-1	This person is:	applicant and inventor
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III-4-7	State of residence	KR
III-5	<b>Applicant and/or inventor</b>	
III-5-1	This person is:	applicant and inventor
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III-5-6	State of nationality	KR
III-5-7	State of residence	KR
III-6	<b>Applicant and/or inventor</b>	
III-6-1	This person is:	applicant and inventor
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III-6-6	State of nationality	KR
III-6-7	State of residence	KR

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<b>III-7</b>	<b>Applicant and/or Inventor</b>	
III-7-1	This person is:	applicant and inventor
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III-7-6	State of nationality	KR
III-7-7	State of residence	KR
<b>III-8</b>	<b>Applicant and/or Inventor</b>	
III-8-1	This person is:	applicant and inventor
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III-8-6	State of nationality	KR
III-8-7	State of residence	KR
<b>IV-1</b>	<b>Agent or common representative; or address for correspondence</b> The person identified below is hereby/has been appointed to act on behalf of the applicant(s) before the competent International Authorities as:	agent
IV-1-1	Name (LAST, First)	LEE, Young-Pil
IV-1-2	Address:	The Cheonghwa Bldg., 1571-18 Seocho-dong, Seocho-gu 137-874 Seoul Republic of Korea
IV-1-3	Telephone No.	82-2-588-8585
IV-1-4	Facsimile No.	82-2-588-8586
IV-1-5	e-mail	iplaw@yplee.co.kr
IV-1-5	Agent's registration No.	9-1998-000334-6
<b>V</b>	<b>Designation of States</b>	
V-1	Regional Patent (other kinds of protection or treatment, if any, are specified between parentheses after the designation(s) concerned)	EP: AT BE BG CH&LI CY CZ DE DK EE ES FI FR GB GR HU IE IT LU MC NL PT RO SE SI SK TR and any other State which is a Contracting State of the European Patent Convention and of the PCT

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<b>V-2</b>	<b>National Patent</b> (other kinds of protection or treatment, if any, are specified between parentheses after the designation(s) concerned)	<b>CN JP US</b>
<b>V-5</b>	<b>Precautionary Designation Statement</b>  In addition to the designations made under items V-1, V-2 and V-3, the applicant also makes under Rule 4.9(b) all designations which would be permitted under the PCT except any designation(s) of the State(s) indicated under item V-6 below. The applicant declares that those additional designations are subject to confirmation and that any designation which is not confirmed before the expiration of 15 months from the priority date is to be regarded as withdrawn by the applicant at the expiration of that time limit.	
<b>V-6</b>	<b>Exclusion(s) from precautionary designations</b>	<b>NONE</b>
<b>VI-1</b>	<b>Priority claim of earlier national application</b>	
VI-1-1	Filing date	<b>27 September 2002 (27.09.2002)</b>
VI-1-2	Number	<b>10-2002-0058764</b>
VI-1-3	Country	<b>KR</b>
<b>VI-2</b>	<b>Priority claim of earlier national application</b>	
VI-2-1	Filing date	<b>22 August 2003 (22.08.2003)</b>
VI-2-2	Number	<b>10-2003-0058337</b>
VI-2-3	Country	<b>KR</b>
<b>VII-1</b>	<b>International Searching Authority Chosen</b>	<b>Korean Intellectual Property Office (KIPO) (ISA/KR)</b>
<b>VIII</b>	<b>Declarations</b>	<b>Number of declarations</b>
VIII-1	Declaration as to the identity of the inventor	-
VIII-2	Declaration as to the applicant's entitlement, as at the international filing date, to apply for and be granted a patent	-
VIII-3	Declaration as to the applicant's entitlement, as at the international filing date, to claim the priority of the earlier application	-
VIII-4	Declaration of inventorship (only for the purposes of the designation of the United States of America)	-
VIII-5	Declaration as to non-prejudicial disclosures or exceptions to lack of novelty	-

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<b>IX</b>	<b>Check list</b>	<b>number of sheets</b>	<b>electronic file(s) attached</b>
IX-1	Request (including declaration sheets)	6	-
IX-2	Description	13	-
IX-3	Claims	3	-
IX-4	Abstract	1	EZABST00.TXT
IX-5	Drawings	3	-
IX-7	TOTAL	26	
<b>Accompanying Items</b>		<b>paper document(s) attached</b>	<b>electronic file(s) attached</b>
IX-8	Fee calculation sheet	✓	-
IX-9	Original separate power of attorney	✓	-
IX-17	PCT-EASY diskette	-	Diskette
IX-19	Figure of the drawings which should accompany the abstract	2	
IX-20	Language of filing of the international application	English	
X-1	Signature of applicant, agent or common representative		
X-1-1	Name (LAST, First)	LEE, Young-Pil	

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10-1	Date of actual receipt of the purported international application	
10-2	Drawings:	
10-2-1	Received	
10-2-2	Not received	
10-3	Corrected date of actual receipt due to later but timely received papers or drawings completing the purported international application	
10-4	Date of timely receipt of the required corrections under PCT Article 11(2)	
10-5	International Searching Authority	ISA/KR
10-6	Transmittal of search copy delayed until search fee is paid	

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11-1	Date of receipt of the record copy by the International Bureau	
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